

United States Patent and Trademark Office



UNITED STATES DEPARTMENT OF COMMERCE
United States Patent and Trademark Office
Address: COMMISSIONER OF PATENTS AND TRADEMARKS
Washington, D.C. 20231
www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.		
10/052,347	01/23/2002	Katsuhide Manabe	P 282475 4113 F00-219-USdiv3-c			
909	590 12/03/2002					
PILLSBURY WINTHROP, LLP			EXAMINER			
P.O. BOX 105 MCLEAN, VA			MULPURI,	MULPURI, SAVITRI		
	• .		ART UNIT	PAPER NUMBER		
			2812			
•		DATE MALE D. 12/02/2002				

Please find below and/or attached an Office communication concerning this application or proceeding.

ال

Office Action Summary

Application No. 10/052,347 Applicant(s)

Art Unit

Manabe et al

Ì
ľ
T
ī
П
П
1
ı
1
Ì
ı
1
ľ
F
Ī
1
ì
ı
ı
i
ľ
1
ı
I
F
ì
ľ
I
 ı
Г
ı
ı
i

			Savitri Mulpuri 28					
_	The MAILING DATE of this communication appears	on the cov	er she	et with t	he corres	pondence address	r	
Period f	or Reply							
THE N - Extens mailing - If the p	ORTENED STATUTORY PERIOD FOR REPLY IS SET MAILING DATE OF THIS COMMUNICATION. ions of time may be available under the provisions of 37 CFR 1.136 (a). In date of this communication. eriod for reply specified above is less than thirty (30) days, a reply within the period for reply is specified above, the maximum statutory period will apply the specified above.	no event, how	ever, ma	y a reply bof thirty (30	e timely filed) days will be	after SIX (6) MONTHS to		
- Failure - Any re	to reply within the set or extended period for reply will, by statute, cause to ply received by the Office later than three months after the mailing date of patent term adjustment. See 37 CFR 1.704(b).	he application t	o become	e ABANDO	NED (35 U.S	i.C. § 133).		
Status								
1) 💢	Responsive to communication(s) filed on <u>Sep 17, 2</u>	2002					·	
2a) 🗌	This action is FINAL . 2b) X This act	tion is non	-final.					
3) 🗆	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11; 453 O.G. 213.							
Disposi	tion of Claims							
4) 💢	Claim(s) 1-52 and 119-127				is/are	pending in the a	pplication.	
4	a) Of the above, claim(s)				is/ar	e withdrawn fror	n consideration.	
5) 🗆	Claim(s)					is/are allowed.		
6) 💢	Claim(s) 1-52 and 119-127					is/are rejected.		
7) 🗆	Claim(s)					is/are objected to	o.	
8) 🗆	Claims							
Applica	tion Papers							
9) 🗆	The specification is objected to by the Examiner.							
10)	The drawing(s) filed on is/are	ea) 🗆 ac	cepted	or b)	objecte	d to by the Exar	niner.	
	Applicant may not request that any objection to the							
11)	The proposed drawing correction filed on		is:	a) 🗆 a	pproved	b) ☐ disapprove	d by the Examiner.	
	If approved, corrected drawings are required in reply	to this Off	ce acti	ion.				
12)	The oath or declaration is objected to by the Exam	iner.						
•	under 35 U.S.C. §§ 119 and 120		. 05		5 440(-)	/-D /8)		
	Acknowledgement is made of a claim for foreign p	priority und	ier 35	U.S.C.	3 119(a)	-(a) or (i).		
a) L	☐ All b)☐ Some* c)☐ None of:	baaa	:	1				
	1. Certified copies of the priority documents have				lication N	Jo.		
	 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority of the priority of the priority of the certified copies of the priority documents have a priority of the priority documents have a priority document of the priority documents have a priority document of the priority of the priority of the priority document of the priority of the pri						·	
	application from the International Bure ee the attached detailed Office action for a list of the	eau (PCT F	lule 17	7.2(a)}.		Tana Madamar Sa	190	
14)	Acknowledgement is made of a claim for domestic	c priority u	nder 3	35 U.S.	C. § 119	(e).		
a) [The translation of the foreign language provision	al applicat	ion ha	s been i	received.			
15)	Acknowledgement is made of a claim for domestic	c priority u	nder 3	35 U.S.0	C. §§ 12	0 and/or 121.		
Attachm								
_	otice of References Cited (PTO-892)	_				No(s)		
	otice of Draftsperson's Patent Drawing Review (PTO-948) formation Disclosure Statement(s) (PTO-1449) Paper No(s).	5) Notice 6) Othe		rmal Patent	Application	(P1O-152)		
ai Piliu	formation Disclosure Statement(s) (PTO-1449) Paper No(s).	o, U Othe						

Art Unit: 2812

DETAILED ACTION

This action is in response to the applicant 's provisions of IDS and amendment to claims filed on 9/17/02

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 19-36, 119-121 are rejected under 35 U.S.C. 102(b) as being anticipated by Sayyah et al.

Sayyah et al discloses a method of growing GaN or AlGaN on sapphire substrate by vapor phase epitaxy MOCVD, HCVD: Sayyah further discloses growing AlN layer in addition AlGaN and GaN layers, by using silane and with TMG, TMA, and ammonia. Sayyah et al discloses flow rate of silane is 10-1200 SCCM to obtain donor concentration of 9 X 10 ¹⁸/cm ³. Since silicon is shallow donor in GaN, the claimed electron concentration is close to that of disclosed silicon concentration of Prior art in the GaN material. In the prior art the measured silicon concentration was limited by the detect ability limit of the technique used to measure the silicon concentration. Based upon the range of flow rates of silane used in the prior art, it is conceivable that a wide range of silicon concentration spanning more than three decades variation has been achieved in the prior art. Sayyah et al do not explicitly teach conductivity. However, the above dopant silicon concentration in the prior art cover the claimed ranges of conductivity.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person

ائن.

Application/Control Number: 10/052347 Page 3

Art Unit: 2812

having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 37-52, 122-127 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sayyah et al. Sayyah et al does teach individual epitaxial layer of AlGaN, GaN, AlN, but does not teach using one of the layers as buffer layer. It is well known that using one of the above mentioned layers as buffer layer to reduce crystal defects in the active layers used for device.

Applicant's arguments with respect to claims 19-52, 119-127 have been considered but are most in view of the new ground(s) of rejection.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to S. Mulpuri whose telephone number is 703-305-5184. The fax phone number for the organization where this application or proceeding is assigned is 70-308-7722.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

SAVITRI MULPURI
PRIMARY EXAMINER